

Special Issue

Phenolic Profiling and Antioxidant Capacity in Agrifood Products (Volume II)

Message from the Guest Editors

This special issue on “Phenolic Profiling and Antioxidant Capacity in Agrifood products” seeks high quality works focus,

1. on developing new functional food and nutraceutical products with high phenolic content and antioxidant potential,
2. on the impact that conventional and advanced food processing technologies [e.g. pulsed electric fields (PEF), pulsed-light (PL), ultraviolet (UV)-light; high pressure processing or high hydrostatic pressure (HPP/HHP); ultrasound; extrusion technology, etc.] have on the phenolic and bioactivity characteristics of industrial foods.

Guest Editors

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Editor-in-Chief

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